

at least one
a liquid crystal layer between the first and second substrates;
at least one uniaxial optical compensation film over the second substrate; and
a first alignment layer having a plurality of first alignment directions over the first substrate.

*Sub D5
C3*
14. (Amended) A method for manufacturing a reflective-type liquid crystal display device, comprising:
providing first and second substrates;
forming a reflective electrode having an opaque metal and being a surface with convex portions over the first substrate;
providing at least one uniaxial optical compensation film over the second substrate; and
forming a first alignment layer having a plurality of first alignment directions over the first substrate.

*Sub D7
C4*
29. (Amended) A [The] method for manufacturing reflective-type liquid crystal display device, comprising:
providing first and second substrates;
providing a liquid crystal layer between the first and second substrates;
forming a reflective electrode having an opaque metal and being a surface with convex portions over the first substrate;
providing at least one uniaxial optical compensation film over the second substrate;
forming a first alignment layer having a plurality of alignment directions over the first substrate; and
forming a second alignment layer over the second substrate.

REMARKS

Favorable reconsideration of this application in view of the foregoing amendments and the following remarks is respectfully requested. Currently, claims 1,3, 4 and 6-39 are pending.

Claims 1, 3, 4 and 6-39 were rejected under 35 U.S.C. 103(a) as being unpatentable over Sugiyama et al. (U.S. Patent No. 5,757,455) in view of Toko (U.S. Patent No. 5,793,459).